

Title (en)

NEW PROCESS FOR THE NITRATION OF AROMATIC COMPOUNDS IN MILD, NON-CORROSIVE CONDITIONS

Title (de)

VERFAHREN ZUR NITRIERUNG VON AROMATISCHEN VERBINDUNGEN VERBINDUNGEN UNTER MILDEN, NICHT KORROSIVEN BEDINGUNGEN

Title (fr)

NOUVEAU PROCEDE DE NITRATATION DE COMPOSES AROMATIQUES DANS DES CONDITIONS DOUCES ET NON CORROSIVES

Publication

EP 0686141 B1 19981209 (EN)

Application

EP 94908531 A 19940225

Priority

- PT 9400001 W 19940225
- PT 10120793 A 19930226

Abstract (en)

[origin: WO9419310A1] The present invention provides a process for the nitration of aromatic substrates. In one process, an aromatic substrate is reacted with a silicate, optionally modified with a metal nitrate, in the presence of an acid anhydride and an organic solvent, followed by the addition of reduced amounts of nitric acid. Isolation of the nitrated products involves filtration, washing and solvent removal. This process can produce either mono- or polynitrated aromatic compounds depending upon the conditions selected and the aromatic substrate. The present invention also provides related processes for the nitration of strongly activated aromatic substrates using only silicates modified with metal nitrate in the presence of acid anhydrides and an organic solvent. All of these processes provide advantages in yield, cost, and safety over the industrial methods of nitration using mixed acids.

IPC 1-7

C07C 201/08; C07C 205/06; C07C 205/12; C07C 205/44; C07C 205/22; C07C 205/23; C07C 205/37; C07C 205/55

IPC 8 full level

C07C 201/08 (2006.01); **C07C 205/06** (2006.01); **C07C 205/12** (2006.01); **C07C 205/22** (2006.01); **C07C 205/23** (2006.01); **C07C 205/37** (2006.01); **C07C 205/44** (2006.01); **C07C 205/55** (2006.01); **C07D 307/70** (2006.01); **C07D 333/42** (2006.01)

CPC (source: EP)

C07C 201/08 (2013.01); **C07D 307/70** (2013.01); **C07D 333/42** (2013.01)

C-Set (source: EP)

1. **C07C 201/08** + **C07C 205/06**
2. **C07C 201/08** + **C07C 205/12**
3. **C07C 201/08** + **C07C 205/22**
4. **C07C 201/08** + **C07C 205/23**
5. **C07C 201/08** + **C07C 205/43**
6. **C07C 201/08** + **C07C 205/44**
7. **C07C 201/08** + **C07C 205/55**
8. **C07C 201/08** + **C07C 205/37**

Designated contracting state (EPC)

AT BE CH DE DK ES FR GB GR IE IT LI LU MC NL PT SE

DOCDB simple family (publication)

WO 9419310 A1 19940901; AT E174325 T1 19981215; DE 69415149 D1 19990121; DE 69415149 T2 19990701; DK 0686141 T3 19990816; EP 0686141 A1 19951213; EP 0686141 B1 19981209; ES 2127381 T3 19990416; GR 3029589 T3 19990630; PT 101207 A 19940831

DOCDB simple family (application)

PT 9400001 W 19940225; AT 94908531 T 19940225; DE 69415149 T 19940225; DK 94908531 T 19940225; EP 94908531 A 19940225; ES 94908531 T 19940225; GR 990400676 T 19990305; PT 10120793 A 19930226